<u>NFORMATION CITED BY APPLICANTS THAT MAY BE MATERIAL TO THE</u>

PROSECUTION OF THE SUBJECT APPLICATION

Y. Granik et al.

Attorney Docket No. MEGC117332

Application No.: 09/898,431

Group Art Unit: 2123

Filed:

July 2, 2001

Title:

METHOD OF COMPENSATING FOR ETCH EFFECTS IN RECEIVED PHOTOLITHOGRAPHIC PROCESSING

Junglodik Centres 5100

U.S. PATENT DOCUMENTS

*Examiner	Cite		Kind	Date		Technoloss
<u>Initials</u>	No.	Document No.	Code	(mm/dd/yyyy)	Name	· · · · · · · · · · · · · · · · · · ·
WH	U1	5,682,323		10/28/1997	Pasch et al.	•
WH	U2	5,801,954		09/01/1998	Le et al.	

FOREIGN PATENT DOCUMENTS

None

OTHER INFORMATION

None

Examiner

Date Considered

*Examiner: Initial if reference considered, whether or not citation is in conformance with M.P.E.P. § 609; draw line through citation if not in conformance and not considered. Include

copy of this form with next communication to applicant.RCT:yc